IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

icant:

Shye-Lin Wu

Examiner:

Filing Date: 2003/7/25

Art Unit:

App. No.:

10/604,485

Docket No.: ADTP0068USA0

Title:

METHOD OF FABRICATING POLYSILICON FILM BY

EXCIMER LASER CRYSTALLIZATION PROCESS

To:

Assistant Commissioner for Patents

P.O.BOX 1450

Alexandria, VA 22313-1450

Subject:

Request for withdrawal as agent

Dear Sir or Madame:

I hereby apply to withdraw as agent for the above identified patent/patent application. The reason for this request is that I am leaving my current office of employment to attend law school.

Although I am requesting to withdraw from the above patent/patent application, Winston Hsu, agent registration No. 41,526, will continue to serve as the primary agent of record for this case. This request for withdraw does not affect the status of Mr. Hsu as the principle agent of record for the above-identified case. Consequently, the correspondence address is NOT affected by this withdrawal. Furthermore, as Mr. Hsu will continue acting as the agent of record, my withdrawing from this case will not affect the client's ability to obtain timely representation. Mr. Hsu, as my employer, has agreed to my withdrawal and will continue handling all aspects of this case. I therefore believe in good faith that the USPTO should find this request for withdrawal acceptable.

Sincerely yours,

/18/2003

Mord Michael Lewis, Patent Agent No.50,478

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